

L Number	Hits	Search Text	DB	Time stamp
1	6152	cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3) (cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor	USPAT	2003/11/25 10:35
2	3338	((cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor) and ((power or current or voltage) with cathode)	USPAT	2003/11/25 10:35
3	2101	((cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor) and ((power or current or voltage) with cathode) and anode	USPAT	2003/11/25 10:36
4	1706	((((cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor) and ((power or current or voltage) with cathode)) and anode) and @ay<=2001	USPAT	2003/11/25 10:38
5	1680	(((((cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor) and ((power or current or voltage) with cathode)) and anode) and @ay<=2001)	USPAT	2003/11/25 10:38
6	594	(((((cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor) and ((power or current or voltage) with cathode)) and anode) and @ay<=2001) and (copper or Cu)	USPAT	2003/11/25 10:43
7	246	(((((cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor) and ((power or current or voltage) with cathode)) and anode) and @ay<=2001) and ((etch or etching or etched or electro\$1etch\$3) same (copper or Cu))	USPAT	2003/11/25 10:46
8	206	((((((cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor) and ((power or current or voltage) with cathode)) and anode) and @ay<=2001) and ((etch or etching or etched or electro\$1etch\$3) same (copper or Cu))) and (mask or plate or hard\$1mask)	USPAT	2003/11/25 11:32
9	12	("3959089" "5256565" "5567300" "5863412" "5993637" "6017437" "6056869" "6077412" "6171467" "6176992" "6299741" "6328872").PN.	USPAT	2003/11/25 11:18
10	2	("4871416" "5686789").PN.	USPAT	2003/11/25 11:28
11	153	((((((cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor) and ((power or current or voltage) with cathode)) and anode) and @ay<=2001) and ((etch or etching or etched or electro\$1etch\$3) same (copper or Cu))) and (mask or plate or hard\$1mask)) and @py<=2001	USPAT	2003/11/25 11:33
12	58	((((((cathode same (etch\$2 or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor) and ((power or current or voltage) with cathode)) and anode) and @ay<=2001) and ((etch or etching or etched or electro\$1etch\$3) same (copper or Cu))) and (mask or plate or hard\$1mask)) and @py<=2001) not plasma	USPAT	2003/11/25 13:28

23	31	((cathode near4 (plurality or second or two)) and semiconductor) and anode) and (electro\$letch or electro\$etching or electro\$polish or electro\$polishing)	USPAT	2003/11/25 13:57
24	15	((((cathode near4 (plurality or second or two)) and semiconductor) and anode) and (electro\$letch or electro\$etching or electro\$polish or electro\$polishing)) not (((electro\$letch or electro\$etching) and semiconductor) and @ay<=2001)	USPAT	2003/11/25 13:55
25	771	electro\$letch or electro\$etching or electro\$polish or electro\$polishing	US-PGPUB; EPO; JPO	2003/11/25 13:58
26	548	(electro\$letch or electro\$etching or electro\$polish or electro\$polishing) and @ay<=2001	US-PGPUB; EPO; JPO	2003/11/25 13:58
27	142	((electro\$letch or electro\$etching or electro\$polish or electro\$polishing) and @ay<=2001) and cathode	US-PGPUB; EPO; JPO	2003/11/25 14:22
29	1	6251283.pn.	USPAT	2003/11/25 14:23
30	1	6251238.pn.	USPAT	2003/11/25 14:23
-	16979	cathode and (etch or etching or electro\$letch\$3 or electro\$polish\$3)	USPAT	2003/11/25 10:34
-	9350	(cathode and (etch or etching or electro\$letch\$3 or electro\$polish\$3)) and semiconductor	USPAT	2003/11/04 10:54
-	7335	((cathode and (etch or etching or electro\$letch\$3 or electro\$polish\$3)) and semiconductor) and (plate or mask)	USPAT	2003/11/04 10:55
-	5378	((cathode and (etch or etching or electro\$letch\$3 or electro\$polish\$3)) and semiconductor) and (plate or mask)) and power	USPAT	2003/11/04 10:57
-	3614	((((cathode and (etch or etching or electro\$letch\$3 or electro\$polish\$3)) and semiconductor) and (plate or mask)) and power) and anode	USPAT	2003/11/04 10:57
-	1242	(((((cathode and (etch or etching or electro\$letch\$3 or electro\$polish\$3)) and semiconductor) and (plate or mask)) and power) and anode) and (cathode same (etch or etching or electro\$letch))	USPAT	2003/11/04 11:04
-	438	((((((cathode and (etch or etching or electro\$letch\$3 or electro\$polish\$3)) and semiconductor) and (plate or mask)) and power) and anode) and (cathode same (etch or etching or electro\$letch))) not plasma	USPAT	2003/11/04 11:18
-	432	((((((cathode and (etch or etching or electro\$letch\$3 or electro\$polish\$3)) and semiconductor) and (plate or mask)) and power) and anode) and (cathode same (etch or etching or electro\$letch))) not plasma) and @ay<=2001	USPAT	2003/11/04 11:19
-	266	((((((cathode and (etch or etching or electro\$letch\$3 or electro\$polish\$3)) and semiconductor) and (plate or mask)) and power) and anode) and (cathode same (etch or etching or electro\$letch))) not plasma) and @ay<=2001) and (solution or etchant or wet)	USPAT	2003/11/04 11:19
-	198	((((((cathode and (etch or etching or electro\$letch\$3 or electro\$polish\$3)) and semiconductor) and (plate or mask)) and power) and anode) and (cathode same (etch or etching or electro\$letch))) not plasma) and @ay<=2001) and (solution or etchant or wet)) and mask	USPAT	2003/11/04 11:31

-	142	(((((cathode and (etch or etching or electro\$1etch\$3 or electro\$1polish\$3)) and semiconductor) and (plate or mask)) and power) and anode) and (cathode same (etch or etching or electro\$1etch))) not plasma) and @ay<=2001) and (solution or etchant or wet)) and mask) not (emit or emitting)	USPAT	2003/11/04 11:32
-	47	("1166378" "1393315" "2689216" "2923671" "3300396" "3317410" "3558464" "3652442" "3808071" "3809642" "3953276" "3962047" "3986911" "4032422" "4118303" "4233416" "4304641" "4323438" "4466864" "4469564" "4596637" "4664760" "4906341" "4931150" "4966647" "5000827" "5023044" "5152878" "5222310" "5228966" "5284554" "5308447" "5318683" "5377708" "5391285" "5421987" "5429733" "5431823" "5435885" "5437777" "5443707" "5447615" "5486282" "5543032" "5807165" "5865984" "5911619").PN.	USPAT	2003/11/04 11:41
-	53	electro\$1etch\$3 and semiconductor and cathode and anode	USPAT	2003/11/04 11:49